

VOR RWY 34
QUONSET STATE (OQU)

MISSED APPROACH: Climbing right turn to 1800 on PVD
VOR/DME R-186 to BRUCE INT/PVD 13.2 DME and hold.

Diagram illustrating the BRUCE INT PVD and CEPU PVD processes. The diagram shows a cross-section of a wafer with a central circular region labeled 'CEPU PVD' and a surrounding annular region labeled 'BRUCE INT PVD'. The CEPU PVD region has a radius of 1800 and a thickness of 1.9 NM. The BRUCE INT PVD region has an outer radius of 1800 and a thickness of 3.3 NM. The diagram also shows the 'WATR PVD' region with a radius of 1700 and a thickness of 0.660. The total thickness of the BRUCE INT PVD region is 3.00 TCH 50. The diagram includes a note 'Remain within 10 NM' and a note '1800'.